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INFORMATION DISCLOSURE STATEMENT BY APPLICANT (use as many sheets as necessary)		Application Number	091683,842
		Filing Date	02/21/2002
		First Named Inventor	Tzu-Li Tsai
		Art Unit	2615
		Examiner Name	
		Attorney Docket Number	ACI P0008114A
Sheet	1	of	1

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Examiner Signature		Date Considered	10/7/04
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